



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

June 6, 2025

IGI Report Number

DESCRIPTION

Shape and Cutting Style

Measurements

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

LG713515421

Report verification at [igi.org](#)

PROPORTIONS

Medium To Slightly Thick (Faceted)

13%

44%

63%

61.9%

Pointed

CLARITY CHARACTERISTICS

KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D

E

F

G

H

I

J

Faint

Very Light

Light

CLARITY

IF

VS¹⁻²

VS¹⁻²

SI¹⁻²

I¹⁻³

Internally Flawless

Very Very Slightly Included

Very Slightly Included

Slightly Included

Included

Sample Image Used



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LABORATORY GROWN DIAMOND

MARQUISE BRILLIANT

18.41 X 8.76 X 5.42 MM

5.06 CARATS

G

VVS 2

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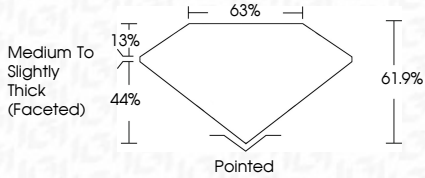
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EXCELLENT

EXCELLENT

NONE

 LG713515421





IGI

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